

Form PTO-1449 (modified)	Atty. Docket No. 2000.092182/TT5077	Serial No. 10/821230 Unknown
List of Patents and Publications for Applicant's INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	Applicant Mark S. Fuselier, Derick J. Wristers and Andy C. Wei	
	Filing Date: 4/8/04 Concurrently Herewith	Group: Unknown 5811
U.S. Patent Documents See Page 1	Foreign Patent Documents See Page 1	Other Art See Page 1

U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date of App.
nm	A1	5,482,871	01-1996	Pollack	438	151	
	A2	5,926,703	07-1999	Yamaguchi <i>et al.</i>	438	163	
	A3	5,950,094	09-1999	Lin <i>et al.</i>	438	409	
	A4	6,069,054	05-2000	Choi	438	423	
	A5	6,180,487	01-2001	Lin	438	407	
	A6	6,204,546	03-2001	Roitman <i>et al.</i>	257	506	
	A7	6,232,163	05-2001	Voldman <i>et al.</i>	438	212	
	A8	6,352,882	03-2002	Assaderaghi <i>et al.</i>	438	155	
	A9	6,407,428	06-2002	Krishnan <i>et al.</i>	257	374	
	A10	6,531,375	03-2003	Giewont <i>et al.</i>	438	407	

Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No
nm	B1	0 687 002 A2	12/13/95	Europe	H01L	21/762	Yes
nm	B2	WO 00/48245	8/17/00	PCT	H01L	21/762	Yes

Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
nm	C1	Baine <i>et al.</i> , "Back Gate Effects in N-Channel Monocrystalline Silicon Devices-on-Glass and Their Suppression by Boron Ion Implantation," <i>Mat. Res. Soc. Symp. Proc.</i> , 558:369-74, 2000
	C2	Chang <i>et al.</i> , "Efficacy of Air in Reducing the Kink Effect on Floating-Body NFD/SOI CMOS," <i>Proc. 1998 IEEE Int'l SOI Conf.</i> , pp. 155-56, 1998
	C3	Ko <i>et al.</i> , "Suppression of Floating Body Effect with SIGE Source Structure for Fully Depleted SOI MOSFET's," <i>Electrochem. Soc. Proc.</i> , 2001-3:239-44, 2001
	C4	Leung <i>et al.</i> , "High Voltage, High Speed Lateral IGBT in Thin SOI for Power IC," <i>Proc. 1996 IEEE Int'l SOI Conf.</i> , pp. 132-133, 1996

EXAMINER:

Kang, Donghee

DATE CONSIDERED:

01-03-05

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